

Electrochemical polymerization of ambipolar carbonyl-functionalized indenofluorene with memristive properties

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ABSTRACT

Carbonyl-functionalized indenofluorene was electropolymerized with a high faradaic efficiency of 85% and the solid state properties of the resulting polymeric thin films were investigated. They displayed modular optical properties depending on their oxidation state. The approach used for inorganic semiconductors was applied to polyindenofluorene derivative. Mott-Schottky analysis evidenced a switching from p-type to n-type electrical conduction, suggesting an ambipolar behaviour of the polymer. As an application, flexible organic memristors were fabricated and resistive switching properties were observed.

1. Introduction

Conjugated polymers constitute a highly promising class of functional materials having wide range of applications in organic optoelectronics. They demonstrated encouraging performances when used as electro-active films in organic and hybrid solar cells, organic field-effect transistors, biosensors, organic light-emitting devices and so on [1–6]. The structural versatility of polymer π -backbones and their tunable redox states provide them advantageous optoelectronic properties. In particular, changing the oxidation state of a polymer π -backbone can significantly modulate electrical and optical responses, which is exploited in several applications including electrochromic devices. The redox state variation also modulates their non-linear optical properties [7,8] making polymers applicable in laser and optical memory fields. In this respect, electrochemistry plays a fundamental role in both deposition and characterization of polymeric films. By electrochemical methods, it is indeed possible to copolymerize two different monomers with the goal of realizing copolymers with different and better properties than the respective homopolymers [9,10]. Among numerous polymeric conjugated systems studied to date, polyindenofluorenes attracted attention originally due to their good chemical stability and

high luminescence quantum efficiency [11]. Later, numerous molecules embedding indenofluorene building blocks were designed and synthesized using efficient synthetic approaches. Indenofluorene (IF) derivatives with good photostability were used as electron donors with C₇₀-based electron acceptors in organic solar cells, which yielded high open circuit voltage and power conversion efficiency of 3% [12]. Some research groups produced small molecules from IF, with wide band gaps to replace fullerenes in organic photovoltaics [13]. Thirion et al. [14] synthesized dispiro (fluorene-9-11'-indeno (2,1a)fluorene-12',9'-fluorenone) and 11,12-dihydroindeno [2,1a]fluorene building blocks and deposited their polymers by using anodic electropolymerization method. They also developed other π -systems based on dispirofluorene-indenofluorene and studied their potential applications in organic light emitting diodes (OLED), which resulted in blue/violet fluorescence with quantum yields of 30–80% [15]. Both single-layered and multi-layered light-emitting devices configurations were developed [16]. Similar IF-based blue fluorescent compounds were employed in multi-layered OLEDs showing a luminous efficiency of 12.2 cd A⁻¹, a power efficiency of 6.08 lm W⁻¹, and an external quantum efficiency of 7.84% at 20 mA cm⁻² [17]. On the other hand, IF-based molecules and polymers were used as solution-processable semiconductors in organic field-

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effect transistors (OFETs). To this end, Usta, Facchetti, Marks et al. [18,29] designed and synthesized high performance *p*-type, *n*-type, and ambipolar semiconductors with good processability and air stability for use in field-effect transistors. In particular, carbonyl-functionalized molecule 2,8-bis(5-(2-ethylhexyl)thien-2-yl)indeno [1,2-*b*]fluorene-6,12-dione showed ambipolar semiconductivity, and dicyanovinylene-functionalized molecule 2,8-bis(5-(2-octyldodecyl)thien-2-yl)indeno [1,2-*b*]fluorene-6,12-dicyanovinylene showed *n*-channel semiconductivity [19–21]. Despite all these studies focusing on indenofluorene-based OFET and OLED devices, their employment in memristive devices, which has potential applications ranging from information storage to neuromorphic systems, has not been yet reported [22,23]. To date, most efforts were directed to inorganic materials-based memristors [24–26,45]. In order to introduce to memristive devices mechanical flexibility and structural versatility, which are essential for flexible and wearable electronics, new organic materials need to be developed. In the last years, only a few polymers, such as polyaniline, polythiophene, poly(ethyleneoxide), have been reported as materials employed for the fabrication of single component - organic memristors. They required, however, a forming cycle to be operative as memory devices, and have shown high $R_{\text{OFF}}/R_{\text{ON}}$ ratios only in controlled atmosphere conditions or after sealing the devices [27,28]. The most performing organic memristors are currently based on blends, mixtures of polymers and hybrid materials and display a $R_{\text{OFF}}/R_{\text{ON}}$ ratio of about 10^4 which is very competitive even with inorganic memristors. Unfortunately, this class of materials suffers of phase separation and ions aggregation that irreversibly affect the long term stability of the devices. In addition, hybrid materials employ expensive materials such as AuNP or graphene so that they are prohibitive for low cost devices applications. In this scenario, it is interesting exploring the potentiality of polyindenofluorenes for memristive devices applications.

In this work, we electropolymerize a carbonyl-functionalized IF derivative monomer (**T-IFDK-T**) having donor-acceptor-donor π -architectures and hydrogen-ended 2-thienyl positions, which yielded the donor-acceptor polymer **poly(IFDK-T2)**. Note that previous attempts to synthesize this polymer from brominated monomer via conventional Yamamoto polymerization yielded totally insoluble solids [18]. Therefore, the electropolymerization approach presented here demonstrates as an effective way of realizing and characterizing **poly(IFDK-T2)** polymeric systems. We also investigate the semiconducting, optical and electronic properties of the resulting polymeric thin films. These results are fundamental for identifying the possible applications of **poly(IFDK-T2)**, considering that some devices operation and performance are influenced by the energy levels mutual position of the constituent materials. In addition, a morphological 3D analysis is carried out by Atomic Force Microscopy (AFM), and both surface structural assessment and thickness evaluation of the organic thin films are reported. Finally, **poly(IFDK-T2)** is employed for the fabrication and the electrical characterization of organic-based memristors.

2. Materials and methods

All reagents were purchased from commercial sources and used without further purification. Conventional Schlenk techniques were used and the syntheses of the monomer **T-IFDK-T** was carried out under nitrogen atmosphere in accordance with our previously published procedures starting from commercial building blocks [30]. The monomeric products were purified by column chromatography and characterized by ^1H and ^{13}C NMR spectroscopy to determine molecular structure and ensure high purity levels for electropolymerizations. The experimental procedure performed during syntheses is as follows:

Synthesis of 2,8-di-3-dodecylthiophene-indeno[1,2-*b*]fluorene-6,12-dione (T-IFDK-T). The reagents **IFDK-Br₂** (0.28 g, 0.63 mmol), 2-tributylstannyl-3-dodecylthiophene (0.415 g, 1.38 mmol) and $\text{Pd}(\text{PPh}_3)_2\text{Cl}_2$ (0.185 g, 0.26 mmol) in anhydrous DMF (40.0 mL) were heated at 125 °C under nitrogen 24 h. The reaction mixture was cooled down to RT and

evaporated to dryness. The crude product was then purified by column chromatography on silica gel using $\text{CHCl}_3/\text{hexanes}$ (8:2) as the eluent to afford the pure product as a dark blue solid (0.186 mg, 38% yield). ^1H NMR (CDCl_3): 0.86–1.64 (m, 46H), 2.71 (t, 4H), 7.04 (d, 2H, $J = 4.5$ Hz), 7.32 (d, 2H, $J = 4.5$ Hz), 7.61 (d, 2H, $J = 7.5$ Hz), 7.63 (d, 2H, $J = 7.5$ Hz), 7.76 (s, 2H), 7.83 (s, 2H) ppm. ^{13}C NMR (CDCl_3): 14.4, 22.96, 29.1, 29.6, 29.7, 29.8, 29.9, 30.0, 31.2, 32.2, 116.3, 121.0, 124.6, 125.5, 130.1, 134.5, 136.1, 136.4, 136.8, 139.8, 140.0, 142.3, 145.9, 192.8 ppm.

Electrochemical polymerization of indenofluorene derivative **T-IFDK-T** was performed in a traditional three-electrode cell under nitrogen pressure. Glassy carbon rod (diameter = 3 mm) and indium-tin oxide/polyethylene terephthalate (ITO/PET) were used as working electrodes. Graphite rod and Ag/AgCl (3.0 M KCl) were used as counter and reference electrodes, respectively. Before each experiment, glassy carbon rod underwent a mechanical treatment with 1 μm diamond and 0.05 μm white alumina suspensions on suitable polishing pads. After the mechanical treatment, the glassy carbon rod was cleaned in de-ionized water and acetone in an ultrasonic bath. ITO/PET electrodes were sonicated in acetone. Dichloromethane (analytical standard, Sigma Aldrich) was used as electrodeposition solvent and 0.1 M tetrabutylammonium hexafluorophosphate (TBAPF₆, for electrochemical analysis 99%, Sigma Aldrich) was used as supporting electrolyte. The monomer concentration was 2×10^{-4} M for each experiment. Both potentiodynamic and potentiostatic techniques were applied for the electrochemical polymerization by means of an Ivium Vertex Potentiostat/Galvanostat. Following the thin-film electrodeposition process, both glassy carbon and ITO/PET working electrodes were washed with dichloromethane (CH_2Cl_2) in order to remove residual monomers and supporting electrolyte. The electrochemical properties of the polymer were studied by cyclic voltammetry in a monomer free solution of 0.1 M TBAPF₆ in CH_2Cl_2 starting from the open circuit potential, in a range between +2.0 V and –2.0 V with respect to the reference electrode. The potential scan rate was 100 mV/s. AFM analysis was used to study the morphological features of the indenofluorene-based polymeric films (Solver P47 PRO (NT-MDT) atomic force microscope). AFM measurements were carried out by means of semi-contact method with the scanning frequency of 1 Hz by using a silicon probe, type NSG, with a tip radius of curvature of 10 nm. AFM measurements were performed in air ambience. The processing of the experimental data and calculation of the surface morphology parameters were carried out by using Image Analysis software package (NT-MDT). Furthermore, by using AFM the values of experimental film thickness were extracted and compared with the theoretical value.

Mott-Schottky ($M - S$) theory was applied to investigate the semiconducting features of the electropolymerized thin films. $M - S$ analysis was performed by recording and elaborating potentiodynamic electrochemical impedance (PDEIS) spectra in a frequency range of 100 mHz–10 kHz by sweeping the potential value from +1.0 V to –1.0 V with respect to the reference electrode. During the measurements, the potential amplitude was 10 mV. A Faraday cage was used in order to minimize external electrical signals.

Optical characterization was carried out by recording the absorbance spectrum of the films as grown. Furthermore the electrochromic response of the polymer was investigated by applying different voltages, in a two-electrode cell endowed with quartz windows and having a path length of 10 mm. The electrolytic solution was 0.1 M TBAPF₆ in CH_2Cl_2 . In particular, absorption spectra were recorded in the UV–Vis range at a scan rate of 100 nm/min by means of a Varian DMS 90 Spectrophotometer and were corrected with respect to the ITO/PET substrate.

In order to verify the memristive behaviour of **poly(IFDK-T2)**, large area devices consisting of a simple PET/ITO/**poly(IFDK-T2)**/Au sandwich structure were fabricated. The active area of each device (about 1 mm^2) was determined by the top Au electrode, which was deposited onto PET/ITO/**poly(IFDK-T2)** via thermal evaporation by using a shadow mask. The underlying ITO film was used as the common bottom

contact. All devices were electrically characterized by performing two-probe I–V measurements by means of a custom developed electronic circuit connected to a Karl Suss probe station [25]. The measurements were performed at room temperature by applying a digital voltage ramp with steps of 50 mV to the Au top contact, while keeping the bottom ITO contact grounded.

3. Theory/calculation

Structures of IFDK-2T oligomers with 1–4 units were optimized with density functional theory (DFT) employing the B3P86-30 hybrid functional with 30% of exact exchange and the 6-31G* basis set. This level of theory was chosen based on previous experience with large conjugated systems [30,31]. For the 4-IFDK-2T cation, we checked the polaron band positions which have strong charge transfer character also with the wB97X-D range-separated hybrid functional [51]. $C_{12}H_{25}$ chains were replaced with methyl groups. Solvent effects of dichloromethane were taken into account with the polarized continuum model (PCM) [32,33]. This does not only account for liquid solvent but also models the dielectric screening in the crystal and accounts therefore for most of the effects of crystal packing [47]. Ionization potentials (IPs) and electron affinity (EA) were calculated with the DSCF method as energy differences between neutral and ionized species. Anions of 4-IFDK-2T with up to 5 additional electrons were evaluated with the 6-31 + G* that contains diffuse functions. Diffuse functions increase EA1 by 0.25 eV. Structure optimization of the ions decreases IPs and increases EAs by about 0.2 eV. In the following we report mainly vertical IPs and EAs. Excited states were calculated with time-dependent (TD) DFT. The excitation spectrum of the 4-IFDK-2T cation is calculated on the optimized geometry of the cation. Charges were analysed with natural population analysis (NPA) [34]. The calculations were done with Gaussian 09 and 16 [35,36]. Spectra are plotted with GabEdit [37].

4. Results and discussion

4.1. Synthesis and characterization

The synthesis of hydrogen-ended T-IFDK-T monomer is shown in Scheme 1. Stille coupling of IFDK-Br₂ with 3-dodecyl-2-trimethylthiophene in the presence of Pd(PPh₃)₂Cl₂ catalysis in DMF yields T-IFDK-T in 38% yield. The monomer was highly soluble in common organic solvents, which allowed its convenient purification by flash chromatography. Monomer structure and purity were characterized by ¹H and ¹³C NMR spectroscopy, which confirmed the proposed molecular structure and indicated excellent purity.

4.2. Electrochemical polymerization

The electrochemical polymerization of (T-IFDK-T) was performed via anodic route by forming radical cations. In particular, the potential was swept, with a constant potential scan rate of 100 mV/s, from the open circuit voltage (0.27 V/(Ag/AgCl)) to +1.8 V/(Ag/AgCl) for 20 cycles in dichloromethane containing 0.1 M TBAPF₆ and 2×10^{-4} M (T-IFDK-T) monomer. The working electrode was glassy carbon and the electrochemical cell was de-aerated with N₂. Fig. 1 displays the typical electropolymerization plot of (T-IFDK-T).

During the first cycle, by increasing the applied potential, current

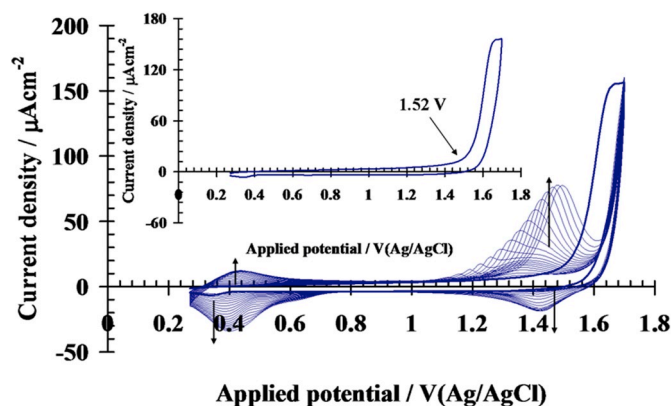


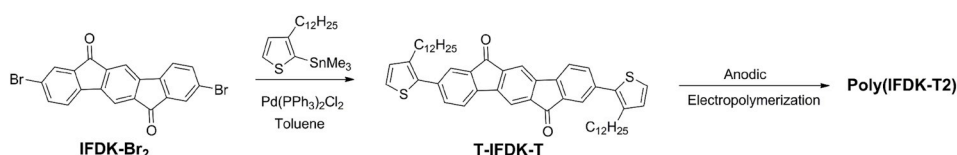
Fig. 1. Potentiodynamic electropolymerization plots of (T-IFDK-T) recorded in dichloromethane 0.1 M TBAPF₆ and 2×10^{-4} M of monomer at a scan rate of 100 mV/s. Inset: Cyclic voltammetry of monomer.

significantly increases starting from 1.52 V/(Ag/AgCl), which corresponds to the monomer oxidation onset. Note that this oxidation potential is higher than that of non-functionalized indeno[1,2-b]fluorene [16] indicating the electron-withdrawing characteristics of carbonyl groups. An oxidation peak at 1.67 V/(Ag/AgCl) corresponding to the radical cation formation at the electrode/electrolyte interface is recorded by switching the working electrode potential toward the anodic direction. Also, the peak value is higher than that of non-functionalized indeno[1,2-b]fluorenes [16]. The second cycle evidences an oxidation onset at around 1.20 V/(Ag/AgCl). This value is lower than the oxidation onset of the monomer, thus suggesting the formation of the polymer onto working electrode. Furthermore, the polymer displays an oxidation peak at around 1.36 V/(Ag/AgCl). As the number of cycles increases, the thickness of the polymeric film increases as well, influencing the redox reaction as suggested by the anodic shift of the oxidation peak [38]. Current density increases with the number of cycles and the oxidation peak becomes more prominent. By inverting the scan direction, a first cathodic process is noticed at 1.42 V/(Ag/AgCl) which indicates that a partial dedoping process occurs. A quasi-reversible redox process is also observed at 0.4 V/(Ag/AgCl). Based on these observations, (T-IFDK-T) electropolymerizes according to the standard mechanism proposed for most of the heterocyclic compounds [39].

4.3. AFM analysis

In order to investigate the morphological features of poly(IFDK-T2), homogeneous and adherent thin films were deposited potentiostatically onto flat ITO/PET electrodes. The electrodeposition of poly(IFDK-T2) was performed by applying 2.2 V/(Ag/AgCl). Fig. 2a and Fig. 2b display the top view morphology in 2D and 3D configurations of poly(IFDK-T2) referred to a $10 \mu\text{m} \times 10 \mu\text{m}$ area. Poly(IFDK-T2) film surface appears granular with an average grain height around 190 nm and a root mean square of 52 nm and an average roughness of 40 nm.

The same sample was used for the experimental determination of the film thickness. Fig. 3 shows the 3D image of poly(IFDK-T2) film recorded close to manually made scratches. Fig. 3a represents the scratch profile and Fig. 3b the 3D view. For the estimation of film thickness, the cross section profiles were built perpendicularly to the scratch over the entire surface and the height drop values were statistically processed and analysed.



Scheme 1. Synthetic routes to T-IFDK-T and the corresponding electropolymerization protocol.

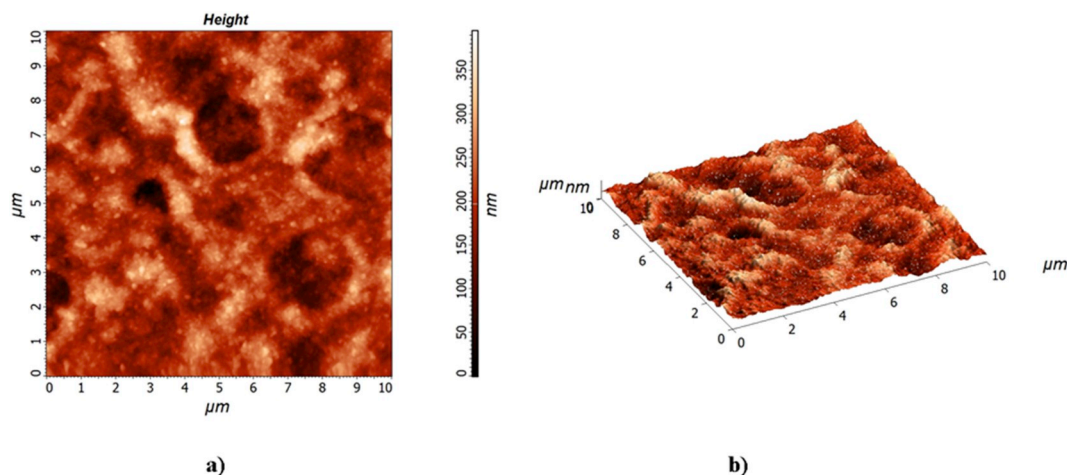


Fig. 2. AFM photographs of a **poly(IFDK-T2)** thin film electrodeposited onto ITO/PET flat electrodes. a) 2D and b) 3D images.

By analysing the cross sections data of **poly(IFDK-T2)** by means of the histogram of the points height on the film-scratch (here not reported), the experimental thickness of 438 nm was extracted. This value was compared with theoretical thickness of almost 510 nm calculated by using the Faraday's law, in order to evaluate the faradaic efficiency of the electropolymerization processes [7]. By considering the charge circulated during the electrochemical deposition, (**T-IFDK-T**) electro-polymerized with a Faradaic efficiency of 85%. This value is higher than the electrochemical yield of polyindeno[1,2-b]fluorene [40].

4.4. Optical and electro-optical properties

In order to gain a deeper insight into the optical properties of the new polymeric system, several thin films were electrodeposited onto transparent and flexible ITO/PET working electrodes. Absorption spectra were recorded in the UV–Vis range and plotted in Fig. 4. As it can be seen, **poly(IFDK-T2)** absorbs in the whole explored wavelength range. In particular, it shows a higher intensity peak at 354 nm and a wide absorption shoulder between 500 and 650 nm. The lower energy transition in **poly(IFDK-T2)** can be assigned to the HOMO-LUMO transition, as confirmed by DFT simulations (see Section 4.6). High energy transitions at around 355 nm can be ascribed to π - π^* transitions into delocalized backbone states.

The analysis of the photo-transitions and the optical band gaps of the polyindeno[1,2-b]fluorene-based thin films were determined by using the Tauc's law:

$$\alpha(\nu) = \frac{A(h\nu - E_g)^n}{h\nu} \quad (1)$$

where $\alpha(\nu)$ is the optical absorption coefficient, h is the Planck constant,

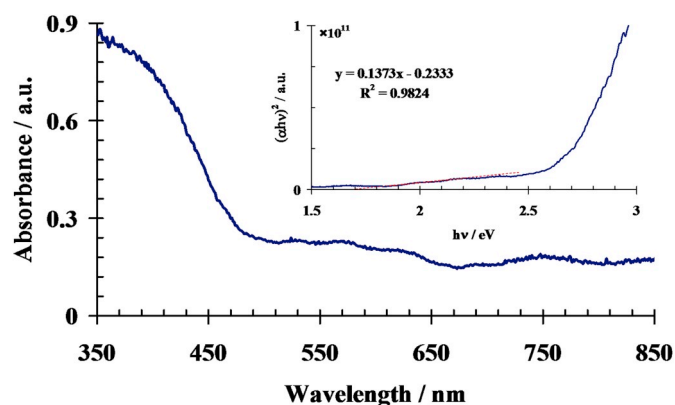


Fig. 4. Absorption spectrum of **poly(IFDK-T2)**. Inset: elaboration by Tauc's law of **poly(IFDK-T2)** absorption spectrum.

ν is the frequency of the incident light, A is a constant, E_g is the optical band gap and n is a power coefficient which assumes different values according to the optical transitions. Under the hypothesis of direct optical transitions and by extrapolating the linear part of the $(\alpha h\nu)^2$ vs $h\nu$ to $(\alpha h\nu)^2 = 0$, optical band gap of 1.70 eV was calculated for **poly(IFDK-T2)** (see inset of Fig. 4).

The modulation of the optical response under an applied electric field was evaluated by using a two electrode quartz cell and by applying different voltages between the polymeric film and the counter electrode in a solution of dichloromethane containing 0.1 M TBAPF₆. Fig. 5a shows the absorbance against wavelength of **poly(IFDK-T2)** under voltages between +1.7 V and −1.0 V and Fig. 5b shows a 3D view of

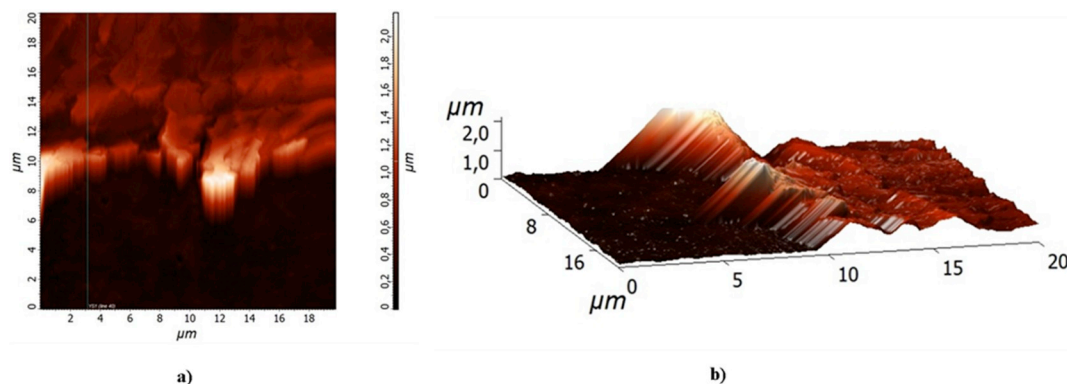


Fig. 3. AFM images of a) **poly(IFDK-T2)** scratch profile and b) **poly(IFDK-T2)** 3D scratch profile.

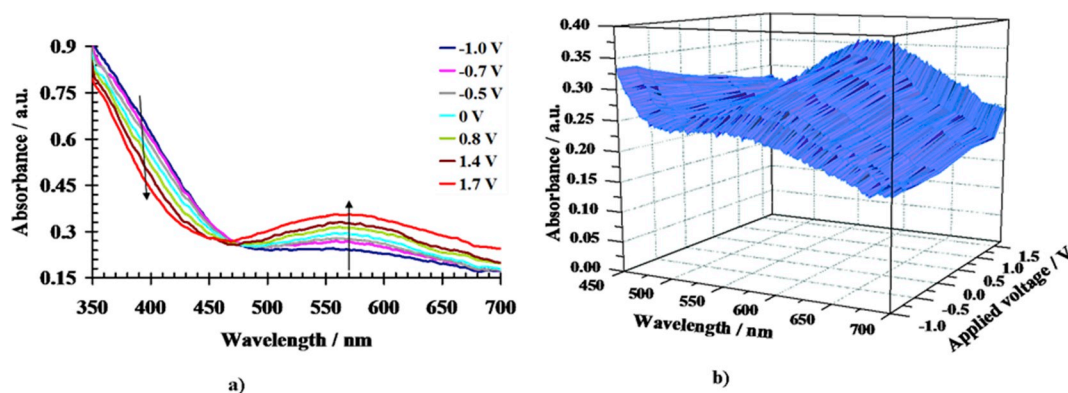


Fig. 5. Optical spectrum modulation of a) **poly(IFDK-T2)** in 2D and b) **poly(IFDK-T2)** in 3D between 450 and 700 nm. The arrows indicate the increasing direction of the applied voltage.

the plot in a wavelength range between 450 and 700 nm.

Poly(IFDK-T2) shows a variation of absorption spectra under the applied voltages. In particular, a hyperchromic shift is noticed by switching from oxidation to reduction voltages in the wavelength range between 350 and 460 nm and a hypochromic shift is noticed by switching from oxidation to reduction voltages in the wavelength range between 460 and 700 nm. As the polymer is oxidized, the intensities of the π - π^* transitions decrease while the intensities of the charge carrier bands at 500–700 nm increase due to polaron formation [41]. 3D absorption spectra of **poly(IFDK-T2)** are shown in Fig. 5b. The spectral changes of the polymer in response to applied different potentials were clearly observed.

4.5. Electrochemical characterization

Poly(IFDK-T2) films deposited onto glassy carbon electrodes were characterized by means of cyclic voltammetry (CV) in a solution made of 0.1 M TBAPF₆ in CH₂Cl₂ by applying a potential scan rate of 100 mV/s under N₂ pressure. Experiments were performed starting from the open circuit values up to 2.0 V/(Ag/AgCl). The reverse scan explored the cathodic branch down to -2.0 V/(Ag/AgCl). Fig. 6 shows the cyclic voltammogram of **poly(IFDK-T2)** thin film. The current vs potential plot evidences multiple redox activity. The forward anodic scan exhibits a potential oxidation onset at 1.24 V/(Ag/AgCl) and two anodic peaks at 1.40 V/(Ag/AgCl) and 1.80 V/(Ag/AgCl), corresponding to the anionic doping and to the overoxidation of the polymer, respectively, due to anions migration from the solution to the polymeric matrix. The potential oxidation onset is lower than that of the monomer, which is a confirmation of the successful deposition of the polymeric film [42]. The reverse scan evidences four cathodic peaks located at 0.47, -0.50, -0.66 and -1.0 V/(Ag/AgCl), respectively. The onset of reduction potential is calculated at -0.40 V/(Ag/AgCl). The first cathodic peak

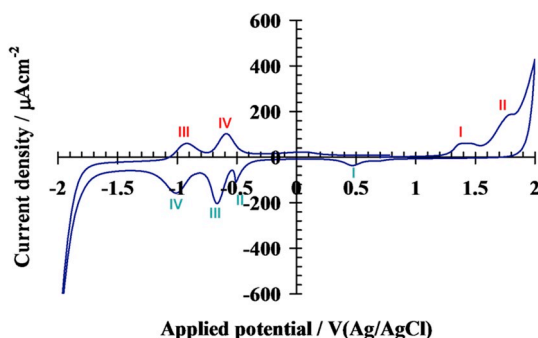


Fig. 6. Cyclic voltammogram of **poly(IFDK-T2)** recorded in 0.1 M TBAPF₆ in CH₂Cl₂ at 100 mVs⁻¹.

may be related to the expulsion of anions from the polymeric matrix corresponding to the discharging of the **poly(IFDK-T2)**. The peak at -1.0 V/(Ag/AgCl) may be ascribed to negative charging processes due to cation insertion. Two anodic peaks at -0.92 and -0.6 V/(Ag/AgCl) are evidenced by inverting the potential scan toward the anodic direction, characterized by comparable current values with respect to the relative cathodic peaks. This result suggests the quasi-reversibility of the doping processes.

Cyclic voltammetry experiments provided poignant information about the polymers electron affinity (EA) and ionization potential (IP). The difference between IP and EA represents the electrochemical band gap, $E_{g,ech}$ of the polymers. Equations (2) and (3) were used to calculate IP and EA with respect to vacuum level [46].

$$IP = -E_{onset,ox} - 4.5 \quad (2)$$

$$EA = -E_{onset,red} - 4.5 \quad (3)$$

where both $E_{onset,ox}$ and $E_{onset,red}$ are referred to normal hydrogen electrode (NHE).

Thus, **poly(IFDK-T2)** has an ionization potential of -5.94 eV and electron affinity of -4.30 eV which suggests a good stability with respect to O₂/H₂O [18]. Thus, an electrochemical band gap of 1.64 eV is calculated. Table 1 summarizes the electrochemical and optical results, where HOMO is approximated at IP and LUMO is calculated as the difference between HOMO and the optical band gap.

4.6. Theoretical analysis

Table 2 summarizes theoretical IPs and EAs, transport gaps (IP-EA), and excitation energies of **IFDK-2T** monomer through tetramer in CH₂Cl₂. The IPs of dimer through tetramer differ only by 0.03 eV and are about 0.4 eV lower than that of the monomer. This shows that the results are convergent to the polymer value already at the dimer stage. The calculated difference between monomer and polymer is slightly larger than the difference between onsets of oxidation of 0.28 V (see above).

The first EAs of the oligomers, including the monomer, differ by only 0.08 eV with a slight tendency of odd number oligomers having higher EAs than even-numbered ones. As there is no increase in EA with chain length, the EAs of the oligomers are the same as that of the polymer. With the 6-31 + G* basis set, EA1 of the tetramer is 3.9 eV. Some geometry relaxation is likely to occur on the time scale of electrochemical reduction. This can be accounted for by optimization of the structure of the anion which increases EA1 by 0.2 eV, bringing it close to the experimental value of 4.3 eV.

The reason for the almost constant IPs and constant EA1s is partial localization of the valence and complete localization of the conduction band (Fig. 7). As the electron accepting units are isolated from each

Table 1
Electrochemical and optical characteristics of **poly(IFDK-2T)**.

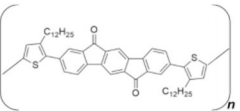
POLYMER	$E_{\text{onset,ox}}$ [V/AgAgCl]	$E_{\text{onset,red}}$ [V/AgAgCl]	IP [eV]	EA [eV]	$E_{g,\text{sch}}$ [eV]	HOMO [eV]	LUMO [eV]	$E_{g,\text{opt}}$ [eV]
	1.24	−0.40	−5.945	−4.305	1.64	−5.945	−4.245	1.70

Table 2
 ΔSCF IPs and EAs, transport gaps (IP-EA), and excitation energies of **IFDK-2T** oligomers with 1–4 repeat units in CH_2Cl_2 .

	IP	EA	IP-EA	$E_{\text{H-L}}$ eV nm (osc)	$E_{\pi-\pi^*}$ eV nm (osc)
Monomer	6.52	3.64	2.88	2.31 537 (0.09)	3.65 340 (0.97)
Dimer	6.11	3.59	2.52	2.18 568 (0.40)	3.13 396 (2.13)
Trimer	6.13	3.67	2.46	2.12 583 (0.50)	3.08 409 (4.42)
Tetramer	6.10	3.61	2.49	2.12 586 (0.79)	3.06 405 (5.86)

other, several consecutive reductions are predicted. The tetramer, for instance can accommodate up to 4 additional electrons with constant binding energies between 3.8 and 3.9 eV. The fifth EA, adding a second electron to one of the units is still positive by 2.37 eV.

As anions are air stable when the EA of the polymer is ~ 4.0 eV [43], these results suggest that **Poly(IFDK-2T)** can accommodate one negative charge per repeat in ambient conditions.

Optical spectra (Fig. 8) likewise converge rapidly with oligomer size. There is almost no difference in absorption peaks of trimer and tetramer apart from oscillator strength increase. The polymer spectrum can therefore be predicted to consist of two principle features at ~ 590 and 405 nm. The lowest allowed excited state is the HOMO-LUMO transition. The oscillator strength (f) of 0.77 for the tetramer is relatively low because localization of the conduction band on indenofluorene and partial localization of the valence band on bithiophene result in small spatial overlap and a small transition dipole moment. The main feature of the spectrum ($f = 5.86$ for the tetramer) excites electrons into higher lying π^* -orbitals that are delocalized. The spectrum of **poly(IFDK-2T)** differs therefore qualitatively from those of homopolymers like for instance polythiophene, which exhibit only one band - a strong HOMO-LUMO absorption. In donor-acceptor polymers with strong acceptors HOMO-LUMO gaps are reduced at the expense of oscillator strength [31]. The consequence of localization for charge

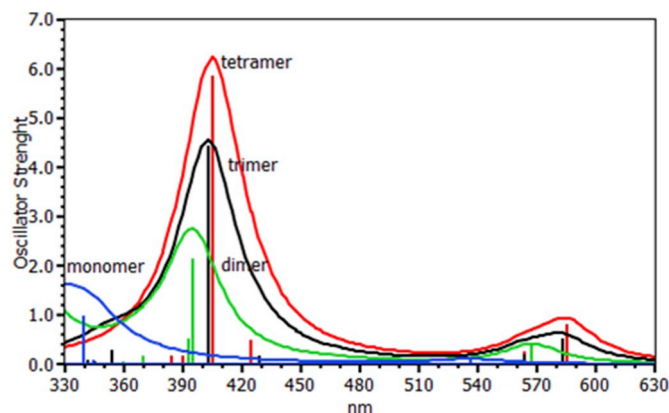


Fig. 8. – Absorption spectra of **IFDK-2T** oligomers.

transport is low charge carrier (hole and electron) mobility along the polymer backbone. Hence, the present systems behave more like molecular crystals than like polymers and high mobilities require good crystallinity and efficient interchain hopping.

Fig. 9 compares spectra of neutral and oxidized **4-(IFDK-2T)** with the wB97X-D functional. The range-separated hybrid functional was employed for this purpose because the low energy polaron band is practically a pure charge transfer state which global hybrids underestimate dramatically. The wB97X-D functional predicts the first absorption of the cation at 854 nm. The higher energy absorptions are similar in energy and in character to the $\pi-\pi^*$ transitions of the neutral form with half of the oscillator strength because they arise largely from the single electron (SOMO-LUMO + X) transition. This explains the experimentally observed decrease in intensity in this region. A new band that arises from a mixture of various electronic transitions at

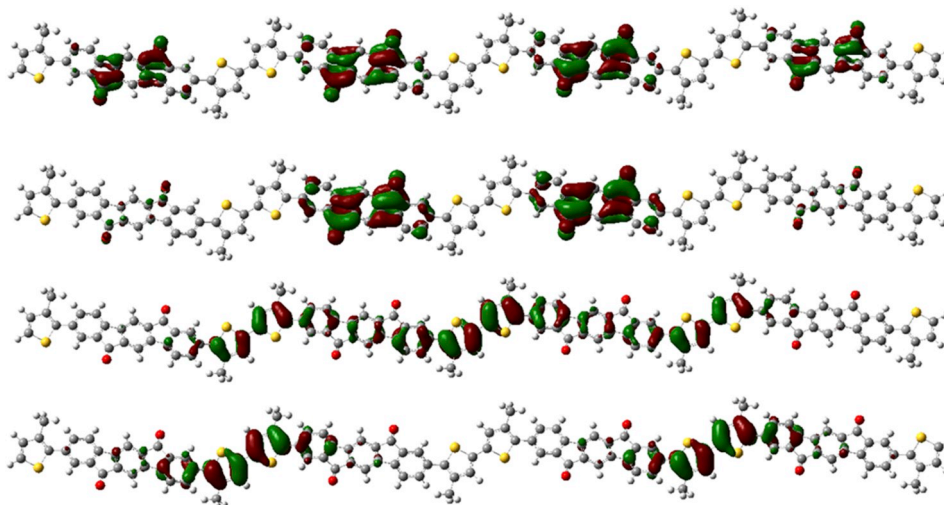


Fig. 7. – HOMO-1, HOMO, LUMO and LUMO + 1 (bottom to top) orbitals of **4-(IFDK-2T)**. Partial localization of occupied orbitals on bithiophene and complete localization of unoccupied orbitals on indenofluorene units is clearly visible.

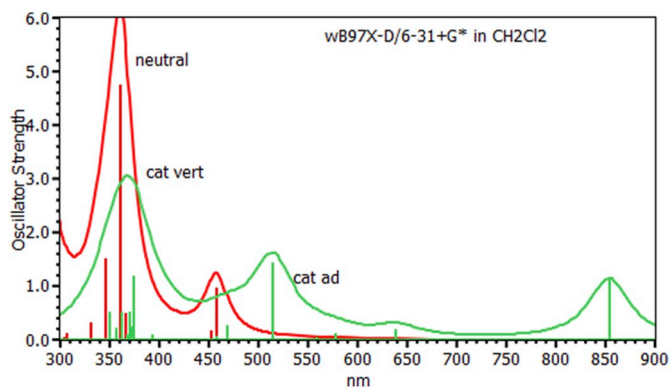
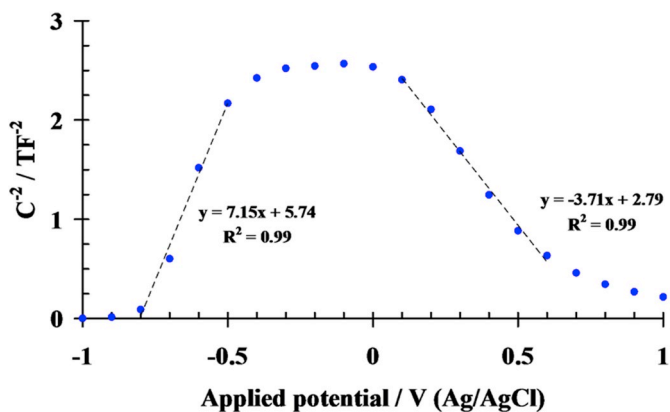


Fig. 9. – Absorption spectra of neutral and oxidized 4-IFDK-2T.

Fig. 10. – Mott-Schottky plots of poly(IFDK-T2) recorded in 0.1 M TBAPF₆ in CH₂Cl₂ at 0.1 kHz.

515 nm. This feature within the uncertainty of our prediction rationalizes the increase in intensity in the experimental spectrum upon oxidation at around 570 nm. The agreement between theoretical and experimental spectra confirms therefore successful polymerization and doping.

4.7. Mott-Schottky analysis

The model of inorganic semiconductor/electrolyte interface was applied in order to get information about the semiconducting properties of poly(IFDK-T2) thin films. Mott-Schottky theory was considered and some fundamental assumptions were done. Under the hypothesis of: absence of surface states and considering the space charge capacitance (C_{sc}) lower than both Helmholtz double layer (C_H) and Gouy-Chapman (C_G) capacitances, the total capacitance can be approximated to the C_{sc} . Potentiodynamic electrochemical impedance spectroscopy (PDEIS) technique was used for detecting the dependence of C_{sc}^{-2} of polymeric films as a function of the applied potential, V . The investigated potential range was between +1.0 V/(Ag/AgCl) and -1.0 V/(Ag/AgCl), where the polymer showed redox activity. Fig. 10 represents the C_{sc}^{-2} vs V of poly(IFDK-T2) at 0.1 kHz.

P(IFDK-T2) exhibits some portions characterized by a linear

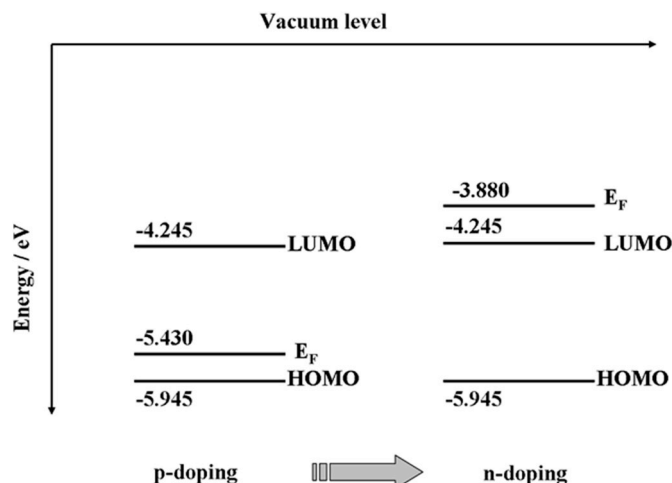


Fig. 11. – Energy levels diagrams of poly(IFDK-T2).

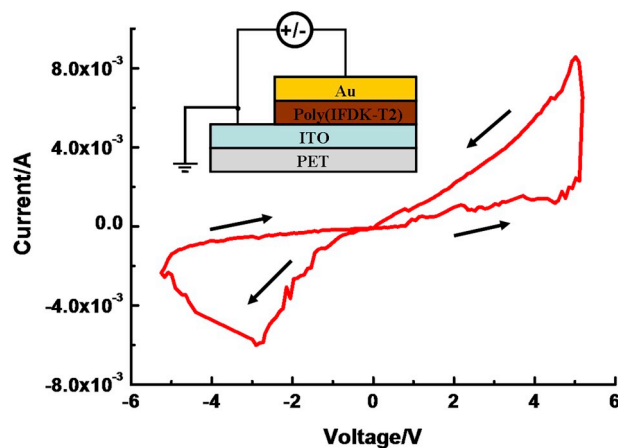


Fig. 12. – Typical I-V characteristic of the fabricated PET/ITO/poly(IFDK-T2)/Au memristor. The inset shows the memristor structure and the electrical arrangement employed for the measurements.

dependence of C_{sc}^{-2} vs V with both negative and positive slopes; this linearity confirms the formation of a space charge layer at the semiconductor side. In particular, a linear portion with negative slope is evidenced in a potential range between 0.1 V/(Ag/AgCl) and 0.6 V/(Ag/AgCl). A positive slope in a potential range between -0.4 V/(Ag/AgCl) and -0.8 V/(Ag/AgCl) is also recorded. This ambipolar feature suggests that poly(IFDK-T2) easily switches from p-type to n-type semiconducting behaviour under suitable electric fields. This confirms the results obtained by cyclic voltammetry which revealed both anionic and cationic doping in the same explored potential range. By considering the Mott-Schottky equation [48]:

$$\frac{1}{C_{sc}^2} = \frac{2}{(\epsilon\epsilon_0 A^2 e N)} \left(V - V_{FB} - \frac{k_B T}{e} \right) \quad (4)$$

where ϵ is the relative permittivity of the polymer, ϵ_0 is the vacuum permittivity, A is the electrode area, e is the electron charge, N is the

Table 3
Semiconducting properties of poly(IFDK-T2).

Polymer	p-doping				n-doping			
	Slope [$F^{-2}V^{-1}$]	N [cm^{-3}]	x-intercept [V/ref. ^a]	V_{FB} [V/ref. ^a]	Slope [$F^{-2}V^{-1}$]	N [cm^{-3}]	x-intercept [V/ref. ^a]	V_{FB} [V/ref. ^a]
Poly (IFDK-T2)	-3.71×10^{12}	2.58×10^{21}	0.750	0.725	7.15×10^{12}	1.34×10^{21}	-0.80	-0.825

^a Ref. = V vs. Ag/AgCl.

charge carriers density, V is applied potential, V_{FB} is the flat band potential, k_B is the Boltzmann's constant and T is the absolute temperature, and by fitting the linear portions, interesting parameters such as the flat band potential and charge carriers density were acquired.

Table 3 summarizes the experimental results obtained by elaborating C_{sc}^{-2} vs V plots, considering: $\epsilon = 3$ [44], $A = 0.07 \text{ cm}^2$, $k_B T = 26 \text{ meV}$, $\epsilon_0 = 8.85 \times 10^{-14} \text{ Fcm}^{-1}$, $e = 1.602 \times 10^{-19} \text{ C}$.

As in the condition of flat band potential there is no charge transfer, it is possible to consider $V_{FB} = V_F$ where V_F is the Fermi level of the organic semiconductors. The location of Fermi level with respect to vacuum (E_F) and the location of HOMO and LUMO levels, reported in Fig. 11, confirmed the p-type and n-type semiconducting behaviour of the polymer.

An interesting result is evidenced when the polymer is n-type doped. **Poly(IFDK-T2)** behaves like a strongly degenerated n-type semiconductor as demonstrated by the position of E_F which is higher than LUMO level. This situation is in correlation with the inorganic degenerated n-type semiconductors, which are characterized by the Fermi level inside the conduction band. The reproducibility of the quasi-metallic behaviour of **poly(IFDK-T2)** was confirmed by further experiments repetitions.

4.8. Memristors characterization

Fig. 12 shows a typical I–V hysteresis curve of a 600 nm-thick **poly(IFDK-T2)**-based memristor. The voltage was swept in the range from -5.2 V to $+5.2 \text{ V}$, following the cycle described by the arrows. The device is initially in its high resistance state (HRS or OFF state). Under positive voltage sweep there is a gradual increase of the current, until a threshold voltage (V_{SET}) of about 4.7 V is reached and a steep increase in the current, leading the device to the low resistance state (LRS or ON state), can be observed. During the negative voltage sweep, the device transforms back to the HRS at about -4.7 V . This behaviour is typical of a bipolar device and may be ascribed, as reported for others organic memristors, to the formation and rupture of Au filaments during operation [49,50]. An average of about 20 cycles was performed before failure of the devices, probably due to a lack of a current compliance imposed during operation. Memristive effect was observed in the absence of a preliminary forming cycle, which can be advantageous to practical applications. A voltage larger than $\pm 4.5 \text{ V}$ needed to be applied, however, before seeing any evident effect. Thinner films required a lower applied voltage to show resistive switching, but failed after a few cycles due to excessive Joule heating.

The R_{OFF}/R_{ON} ratio, measured at -0.9 V , was 4.05.

5. Conclusions

Indenofluorene-based monomer (**T-IFDK-T**), functionalized with carbonyl moiety, is electrochemically polymerized for the first time via an anodic route. The stronger electron-withdrawing behaviour of carbonyl group allows the anodic polymerization at higher overpotential values with respect to indenofluorene. The investigation about the semiconducting properties reveals an ambipolar behaviour with a quasi metallic feature in the case of n-doped **poly(IFDK-T2)**. This interesting result may be ascribed to the strong electron withdrawing behaviour of carbonyl functionalized polymer. The memristive behaviour of **poly(IFDK-T2)** was proved by fabricating and electrically characterizing mm-scale PET/ITO/**poly(IFDK-T2)**/Au memristors. The fabricated flexible memristive devices exhibit bipolar resistive switching properties with a R_{OFF}/R_{ON} ratio of 4.05 which needs to be improved for memory applications. However, the possibility of employing air-stable **poly(IFDK-T2)**-based memristors, without carrying out a prior forming process and without cautions due to the exposition to atmosphere, makes this material an interesting candidate for low cost flexible resistive random access memories.

Declaration of interests

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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